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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/776,438	02/10/2004	Lawrence C. Gunn III	LUX-P021	2909
75	590 02/02/2006		EXAMINER	
Fernandez & Associates, LLP			BLEVINS, JERRY M	
PO Box D Menlo Park,CA 94026-6402			ART UNIT	PAPER NUMBER
Weine Lan, O	11) 1020 0 102		2883	
			DATE MAILED: 02/02/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

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	•	Application No.	Applicant(s)	
Office Action Summany		10/776,438	GUNN ET AL.	•
	Office Action Summary	Examiner	Art Unit	
		Jerry Martin Blevins	2883	
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with the c	correspondence address	
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. Period for reply is specified above, the maximum statutory period to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communicatio D (35 U.S.C. § 133)	
Status				
	Responsive to communication(s) filed on <u>04 Jac</u> This action is FINAL . 2b) This Since this application is in condition for alloward closed in accordance with the practice under Expression 1.	action is non-final. nce except for formal matters, pro		s .
Dispositi	on of Claims			
5)	Claim(s) 1-99 is/are pending in the application. 4a) Of the above claim(s) 1-17,26,27,38-40 and Claim(s) is/are allowed. Claim(s) 18-25,28-37 and 41-50 is/are rejected to. Claim(s) are subjected to. Claim(s) are subject to restriction and/or on Papers The specification is objected to by the Examine The drawing(s) filed on 10 February 2004 is/are Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examine Replacement drawing sheet Replacement drawing sheet Replacement drawing sheet Replacement drawing sheet Replacement d	d 51-99 is/are withdrawn from cords. I. r election requirement. r. e: a) ⊠ accepted or b) □ objected drawing(s) be held in abeyance. See ion is required if the drawing(s) is objected to the drawing(s) is objecte	d to by the Examiner. e 37 CFR 1.85(a). lected to. See 37 CFR 1.121(d).
Priority ι	ınder 35 U.S.C. § 119			
a)[Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureausee the attached detailed Office action for a list	s have been received. s have been received in Application rity documents have been received u (PCT Rule 17.2(a)).	on Noed in this National Stage	
2) ☐ Notic 3) ⊠ Inforr	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date <u>2/26/04,3/03/05</u> .	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:		

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DETAILED ACTION

Election/Restrictions

Claims 1-17, 26, 27, 38-40, and 51-99 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to nonelected inventions (claims 26, 27, and 51-72), to a nonelected species (claims 1-17, 38-40, and 74-85), and to a nonelected subspecies (claims 73 and 86-99), there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 01/04/2006.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 18-20 and 24 are rejected under 35 U.S.C. 102(b) as being anticipated by US Patent to Myers et al., number 5,473,721.

Regarding claim 18, Myers teaches an integrated optical apparatus (Figure 6) comprising: a planar waveguide on a substrate (column 5, lines 40-52); the waveguide having an elongate guiding portion (Figure 6) and a grating coupler (110); the grating coupler comprising a plurality of gratings having respective scatter-cross-sections adapted to scatter light along a portion of a predetermined optical path (Figure 6 and column 5, lines 40-52) and a gas-filled cavity (column 5, lines 40-52), at least a portion

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of which is in the substrate; the cavity positioned with respect to the gratings such that light scattered outside the portion of the optical path is reflected by the cavity towards the gratings (column 5, lines 40-52).

Regarding claim 19, Myers teaches that the grating coupler includes sidewalls to confine the light in a transverse direction (column 4, line 47 – column 5, line 12).

Regarding claim 20, Myers teaches that the grating coupler comprises a channel waveguide (column 2, lines 13-29).

Regarding claim 24, Myers teaches that the gas-filled cavity is filled with air (column 5, lines 40-52).

Claim 28 is rejected under 35 U.S.C. 102(b) as being anticipated by US Patent to Friesem et al., number 6,215,928.

Regarding claim 28, Friesem teaches an integrated optical apparatus (Figure 2) comprising: a planar waveguide (22) having an elongated guiding portion and a grating coupler (24); the grating coupler comprising: (a) a plurality of gratings having a respective scatter-cross-sections adapted to scatter light along at least a portion of a predetermined optical path (Figure 2 and column 4, lines 24-34), (b) a cladding (26) on the plurality of gratings; and (c) an anti-reflection coating (28) on the cladding for reducing reflections.

Claims 37 and 45 are rejected under 35 U.S.C. 102(b) as being anticipated by US Patent to Welch et al., number RE37,354.

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Regarding claim 37, Welch teaches an integrated optical apparatus (Figure 9), comprising: a planar waveguide (112) having an elongate guiding portion and a grating coupler (119), the coupler having a flared waveguide portion (114) comprising a relatively narrow end portion and a relatively wide end portion (Figure 9), the flared portion having a grating (119) positioned to couple light between the coupler and an optical element (column 10, lines 7-26 teach that the apparatus couples light without specifying an optical element, but an optical element would necessarily exist in order for the apparatus to couple light), wherein the grating comprises curved elongate scattering elements having curvatures defined by substantially elliptical paths (Figure 9) so as to couple plane waves between the waveguide grating coupler and the optical element.

Regarding claim 45, Welch teaches a cladding over the grating and an antireflection coating over the cladding for reducing reflections (column 9, line 46 – column 10, line 6).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 21-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Myers in view of US Pre Grant Publication to Haronian, number 2003/0108274.

Regarding claims 21-23, Myers teaches the limitations of the base claim 18. Myers does not teach that the substrate comprises a silicon wafer with a silicon dioxide layer and one or more layers of material formed on the silicon wafer. Haronian teaches a waveguide on a substrate wherein the substrate comprises a silicon wafer with a silicon dioxide layer and one or more layers of material formed on the silicon wafer (Figure 22 and page 9, paragraph 108). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the substrate of Myers with the substrate of Haronian. The motivation would have been to protect the waveguide (page 9, paragraph 108).

Claim 25 is rejected under 35 U.S.C. 103(a) as being unpatentable over Myers in view of US Patent to Borak et al., number 6,003,340.

Regarding claim 25, Myers teaches the limitations of the base claim 18. Myers does not teach that the waveguide comprises cladding wherein the gas-filled cavity is in at least a portion of the cladding. Borak teaches a waveguide with a cladding, wherein a cavity extends in at least a portion of the cladding (column 4, lines 23-49). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the waveguide and cavity of Myers with the waveguide and cavity of Borak, wherein the cavity extends in at least a portion of the waveguide cladding. The motivation would have been to improve the coupling between the waveguide grating coupler and the cavity.

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Claims 29-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Friesem in view of US Patent to Snavely et al., number 4,173,778.

Regarding claims 29-31, Friesem teaches the limitations of the base claim 28. Friesem does not teach that the coating comprises a multilayer, quarter-wave stack, wherein the stack comprises multiple layers of relatively high and low index material having thicknesses selected to provide reduced reflection for light of a predetermined wavelength incident on the coating at a predetermined angle. Snavely teaches an anti-reflection coating comprises a multilayer, quarter-wave stack, wherein the stack comprises multiple layers of relatively high and low index material having thicknesses selected to provide reduced reflection for light of a predetermined wavelength incident on the coating at a predetermined angle (column 10, line 26 – column 14, line 38). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the coating of Friesem with the coating of Snavely. The motivation would have been to improve the reduction of reflection at desired wavelengths.

Regarding claim 32, Friesem in view of Snavely teaches the limitations of the base claim 31. Friesem also teaches an optical element (Figure 1, laser 10) oriented with respect to the grating coupler (12, seen in greater detail in Figure 2) so as to provide an optical path directed at the predetermined angle with respect to the grating coupler, the grating coupler coupling light between the planar waveguide and the optical element (column 3, line 26 – column 4, line 34).

Regarding claims 33-36, Friesem teaches the limitations of the base claim 28.

Friesem does not teach that the coating comprises alternating layers of semiconductor

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(silicon) and dielectric material selected from the group consisting of oxide and nitride (which would necessitate multiple layers of dielectric material). Snavely teaches an anti-reflection coating comprising alternating layers of semiconductor (silicon) and dielectric material selected from the group consisting of oxide and nitride (column 6, lines 21-45). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the coating of Friesem with the coating of Snavely. The motivation would have been to improve the reduction of reflection at desired wavelengths.

Claims 41-43 are rejected under 35 U.S.C. 103(a) as being unpatentable over Welch in view of Myers.

Regarding claims 41-43, Welch teaches the limitations of the base claim 37.

Welch also teaches that the elongate scattering elements have respective scatter cross-sections adapted to scatter light along at least a portion of a predetermined path (column 10, lines 7-26). Welch does not teach a air-filled cavity positioned with respect to the grating such that light scattered outside the portion of the optical path is reflected by the cavity towards the grating, and a substrate, wherein the waveguide is disposed over the substrate and at least a portion of the cavity being in the substrate. Myers teaches an integrated optical apparatus (Figure 6) comprising: a planar waveguide on a substrate (column 5, lines 40-52); the waveguide having an elongate guiding portion (Figure 6) and a grating coupler (110); the grating coupler comprising a plurality of gratings having respective scatter-cross-sections adapted to scatter light along a portion

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of a predetermined optical path (Figure 6 and column 5, lines 40-52) and a gas-filled cavity (column 5, lines 40-52), at least a portion of which is in the substrate; the cavity positioned with respect to the gratings such that light scattered outside the portion of the optical path is reflected by the cavity towards the gratings (column 5, lines 40-52). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Welch with the teaching s of Myers. The motivation would have been to improve coupling between the grating and the waveguide.

Claim 44 is rejected under 35 U.S.C. 103(a) as being unpatentable over Welch in view of Myers as applied to claim 43 above, and further in view of Borak.

Regarding claim 44, Welch in view of Myers teaches the limitations of the base claim 43. Welch in view of Myers does not teach that the waveguide comprises cladding wherein the gas-filled cavity is in at least a portion of the cladding. Borak teaches a waveguide with a cladding, wherein a cavity extends in at least a portion of the cladding (column 4, lines 23-49). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the waveguide and cavity of Welch in view of Myers with the waveguide and cavity of Borak, wherein the cavity extends in at least a portion of the waveguide cladding. The motivation would have been to improve the coupling between the waveguide grating coupler and the cavity.

Claims 46-50 are rejected under 35 U.S.C. 103(a) as being unpatentable over Welch in view of Snavely.

Regarding claims 46-50, Welch teaches the limitations of the base claim 45.

Welch does not teach that the coating comprises a multilayer stack of alternating layers of semiconductor (silicon) and dielectric material selected from the group consisting of silicon dioxide and silicon nitride (which would necessitate multiple layers of dielectric material). Snavely teaches an anti-reflection coating comprises a multilayer stack of alternating layers of semiconductor (silicon) and dielectric material selected from the group consisting of silicon dioxide and silicon nitride (column 6, lines 21-45). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the coating of Welch with the coating of Snavely. The motivation would have been to improve the reduction of reflection at desired wavelengths.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jerry Martin Blevins whose telephone number is 571-272-8581. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Frank G. Font can be reached on 571-272-2415. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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JMB

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